

# Chemicals contained in products

## Package-type

Epson Package name; **VFPGA10H-240 / Halogen free**

JEITA Package name; **(P-VFPGA-240-1010-0.50)**

Solder ball Type; **Lead(Pb) Free**

Weight; **0.16 [g]** \*Note1

Part	Subpart	Subpart weight [mg]	Substance name	CAS No.	Content *Note2		Application		
					[mg]	[ppm]			
IC Die	IC Die	10.5	Silicon	7440-21-3	10.5	999894	Base material		
			Boron	7440-42-8	0.00002	2	Dopant		
			Phosphorus	7723-14-0	0.00005	5	Dopant		
			Aluminum	7429-90-5	0.0002	20	Metalization		
			Arsenic *Note3	7440-38-2	0.00005	5	Dopant		
			Fluorine *Note3	7782-41-4	0.00002	2	Dopant		
			Titanium *Note3	7440-32-6	0.0002	20	Metalization		
			Molybdenum *Note3	7439-98-7	0.0002	20	Metalization		
			Tungsten *Note3	7440-33-7	0.0003	30	Metalization		
			Cobalt *Note3	7440-48-4	0.00002	2	Metalization		
	Stress buffer coat	0.21	Polyimide	-	0.21	1000000	Stress buffer coat *Note4		
Package	Substrate	38.87	Glass-cloth	-	6.8	132000	Reinforcement		
			Silica	-	1.6	66000	Filler		
			Epoxy resin	-	7.6	164300	Base material		
			Acrylate resin	-	2.3	85000	Base material		
			Pigment	-	0.98	49300	Additive		
			Organic filler	-	0.130	3400	Filler		
			Arsenic	7440-38-2	0.036	85	Burning resistance		
			Chromium compound	-	0.0011	14	Burning resistance		
			Copper	7440-50-8	16.3	419901	Copper foil		
			Nickel	7440-02-0	2.5	64000	Plating		
			Gold	7440-57-5	0.62	16000	Plating		
			Die Bonding material	2.71	Epoxy resin	-	1.80	670000	Adhesive
					Acrylic resin	-	0.91	330000	Adhesive
	Solder ball	19.01	Tin	7440-31-5	18.2	957500	Solder ball		
			Silver	7440-22-4	0.67	35000	Solder ball		
			Copper	7440-50-8	0.140	7500	Solder ball		
	Bonding Wire	4.20	Gold	-	4.2	1000000	Conductor		
	Mold resin	84.49	Epoxy resin	-	4.2	50000	Base material		
			Silica	60676-86-0/-	73.8	873000	Filler		
			Carbon black	1333-86-4	0.170	2000	Coloring agent		
			Hardening chemical(ex:Phenol resin)	-	4.2	50000	Base material		
			Organic phosphorous compound	-	0.42	5000	Hardening accelerator		
			Others	-	1.70	20000	Additive		

Regarding the information of chemical substances

\*Note1 The weight might be somewhat different depending on an individual built-in IC-chip specification like the size etc.

\*Note2 Content data are estimated values based on supplier information and intended levels of content in product.

Actual measurements may vary from these values somewhat.

\*Note3 Use or not-use of these substances depends on individual built-in IC-chip specification.

\*Note4 The stress buffer coat may not be used depending on the individual model.